

ECE 310 - Lecture 3

Chapter 2 of the
Textbook

Basics of Semiconductor Physics

↳ Microelectronics → integrated circuits designed at μm scale

↳ Semiconductor Device Theory
" physics "

Semiconductors

Band diagrams

charge carriers → current flow →

Doping of semiconductor

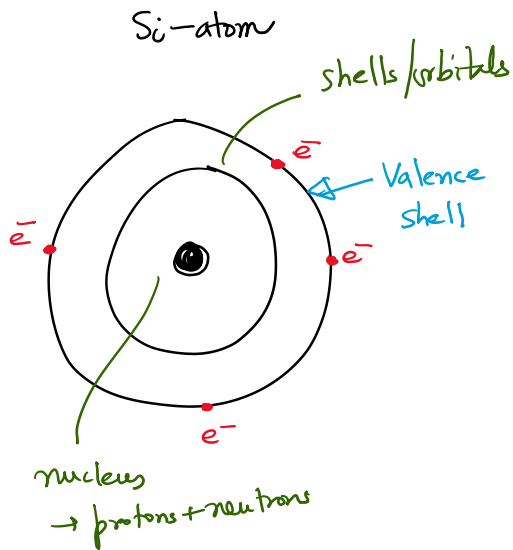
Devices

* Diodes (pn junction) ←

* Transistors ←

↳ MOSFET ←

↳ BJT



* Chemical activity is determined by the valence shell electrons (8 in outer shell)

Na → 1e in outer shell ← highly active donor (I)

Cl → 7e ← highly active recipient (VII)

$\text{Na}^+ - \text{Cl}^-$ electrostatic bond

Ne → 8e ← inert inactive

3, 4, 5

III, IV, V

↓

Si ← most popular material in microelectronics

<u>III</u>	<u>IV</u>	<u>V</u>
<u>B</u>	C	N
Al	Si	<u>P</u>
Ga	Ge	<u>As</u>

Semiconductor \rightarrow Si \rightarrow IV

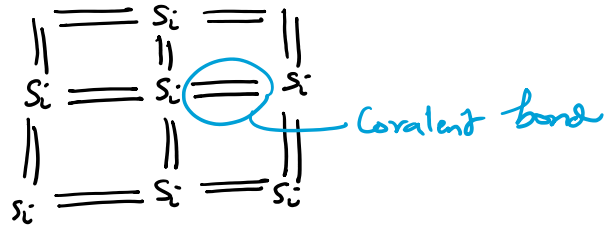
GaAs
GaN
InP

III-V

} compound semiconductor

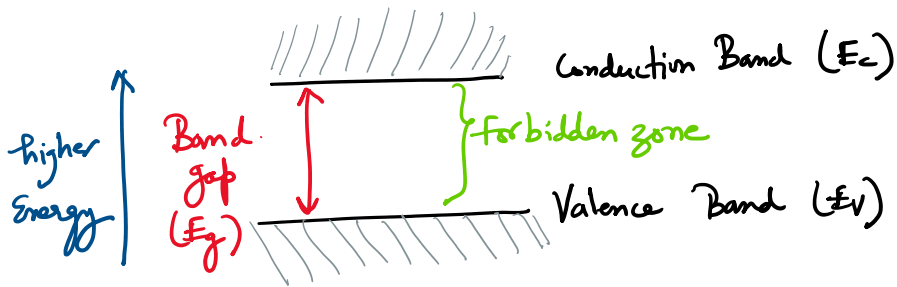
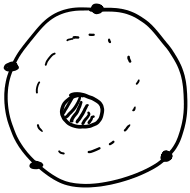
periodic Lattice

Covalent bonds



In crystalline silicon, Si atoms form covalent bonds with their neighboring atoms.

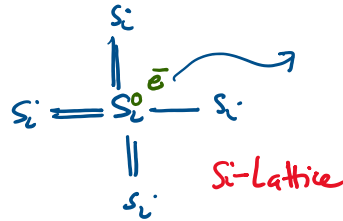
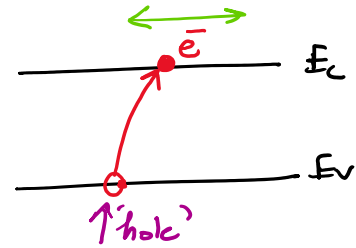
Because of periodicity in the crystal, outer shells of the atoms merge to form "Energy Bands"



* Conduction band is responsible for electron current flow.
Results derived from
* Quantum physics

at $T = 0\text{K}$

↳ valence electrons are confined to their covalent bonds



as $T \uparrow$ electrons gain thermal energy and few of them break the bonds and act as charge carriers
 ↳ "free electrons"

Holes: the void left by the electron is called a hole

free electrons \rightarrow always in the conduction band

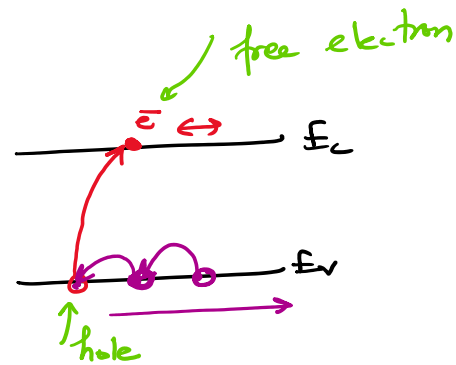
holes \rightarrow always in the valence band

\rightarrow Holes can freely move in the V.B.

\rightarrow contributes to conduction in the semiconductor

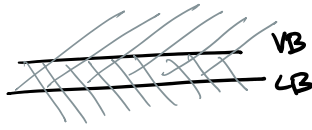
Current \rightarrow (free) electrons in C.B.
 \rightarrow holes in the V.B.

* Electron-hole pair generation, recombination



Metals

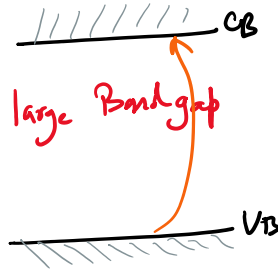
Cu, Al, Au, Ag



CB & VB overlap
↳ large amount of e^- are available for conduction
↳ high conductivity (σ)

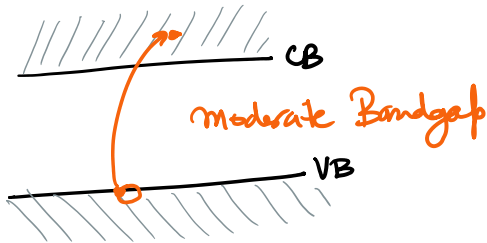
Insulators

SiO_2 , plastics, wood



No conduction

Semiconductors



* easy for an electron in VB to hop to CB

* not as conductive as metals

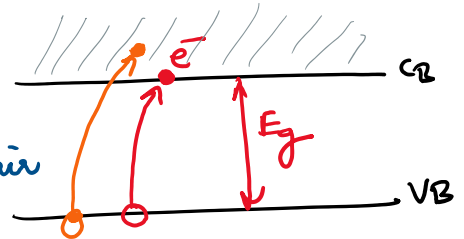
* Can control the conductivity to create "intelligent devices"

↳ logic gates

↳ amplifiers

Bandgap Energy

* bandgap energy is the minimum amount of energy to create an electron-hole pair



for Si , $E_g = 1.12 \text{ eV}$ ← fundamental property of material

* How many free electrons are created at a given temperature

$$n_i = 5.2 \times 10^{15} \cdot T^{3/2} \cdot \exp\left(\frac{-E_g}{2kT}\right) \text{ electrons/cm}^3$$

↑ intrinsic carrier density

$k \equiv$ Boltzmann constant = $1.38 \times 10^{-23} \text{ J/K}$

$$E_g \downarrow \Rightarrow -E_g \uparrow \Rightarrow \exp\left(\frac{-E_g}{2kT}\right) \uparrow \Rightarrow n_i \uparrow$$

$$T \uparrow \Rightarrow T^{3/2} \uparrow$$

$$\frac{E_g}{2kT} \downarrow \Rightarrow \frac{-E_g}{2kT} \uparrow \Rightarrow \exp\left(\frac{-E_g}{2kT}\right) \uparrow \Rightarrow n_i \uparrow$$

Ex 2.1

$E_g = 1.12 \text{ eV}$ for Si

$T = 300\text{K} \Rightarrow 27^\circ\text{C}$
room temperature

$$n_i|_{T=300\text{K}} = 1.08 \times 10^{10} \text{ cm}^{-3}$$

5 orders of magnitude

$$n_i|_{T=600\text{K}} = 1.54 \times 10^{15} \text{ cm}^{-3}$$

Silicon has $5 \times 10^{22} \text{ atoms/cm}^3 \equiv N_{\text{Si}}$

$$\frac{n_i}{N_{\text{Si}}} = \frac{10^{10}}{5 \times 10^{22}} = \underbrace{(5 \times 10^{12})^{-1}}_{\text{5 Trillions}}$$

\Rightarrow only one in 5T atoms creating free electron at room temp.

$n_i \Rightarrow$ intrinsic carrier density

\hookrightarrow pure crystalline semiconductor \Rightarrow no impurities!

Add impurities to the semiconductor crystal (Si)

\hookrightarrow Extrinsic semiconductor.